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**IMAGE SENSOR WITH CHARGE BINNING AND DUAL CHANNEL
READOUT**

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**IMAGE SENSOR WITH CHARGE BINNING AND DUAL CHANNEL
READOUT**

FIELD OF THE INVENTION

5 The present invention pertains to semiconductor based image sensors such as Active Pixel image sensors (APS), and Passive Pixel image sensors (PPS), and more particularly, to such APS and PPS with charge binning, high sensitivity, low noise, and parallel channel readout.

BACKGROUND OF THE INVENTION

10 APS and PPS are x-y addressable solid state imagers wherein each pixel contains both a photosensing element and a select element. For APS, each pixel also contains at least one other active circuit component. In both APS and PPS, incident illumination is converted to a signal (either a voltage or current
15 signal). The signal represents the amount of light incident upon a pixel photosite. This signal is typically readout one row at time, and the signals for a given row are stored temporarily in a circuit associated with each column of the image sensor. This column circuit is typically constructed to fit into the size or pitch of the pixel.

20 For many digital imaging applications, it is desirable to have a large number of pixels in a given size image sensor in order to increase the resolution of the image sensor. As the resolution requirement increases, the required pixel size decreases. As the pixel size decreases, several image sensor design and performance disadvantages are encountered. First, it becomes
25 increasingly more difficult to construct a low noise column storage and readout circuit. Second, smaller pixels have lower sensitivity and can provide inadequate signal levels for low levels of illumination. Third, for a large number of pixels, the readout time will become longer. In many cases, a camera is required to produce video as well as still images.

30 Typically the video rate desired is 30 frames per second. Prior art APS and PPS sensors have accomplished video rate data from large resolution sensors by windowing or sub-sampling of the image array using the x-y

addressability feature of APS and PPS sensors. While this approach provides video rate data, it does so by selective readout of the small pixels and still has poor image quality in low light level environments, and produces aliasing image artifacts.

5 Some APS and PPS sensors also include on sensor white balance by placing a programmable gain amplifier PGA in the readout path, which gain can change at a pixel data rate. For high resolution sensors, this has the disadvantage of requiring higher performance PGAs.

10 From the foregoing discussion it should be apparent that there remains a need within the prior art for a high resolution, small pixel device that provides high readout rate, variable resolution while retaining low noise and high sensitivity.

SUMMARY OF THE INVENTION

15 According to the present invention, there is provided a solution to problems of the prior art. In the present invention, an APS device with a selectable channel readout architecture is provided that enables small pixels and high resolution sensors, low noise column storage and readout circuitry, and adjacent same color sample averaging for high performance lower resolution
20 readout.

 According to another embodiment of the present invention, the selectable channel readout architecture is employed with a shared amplifier pixel to provide selectable charge domain binning to further improve sensitivity and low light signal to noise performance.

25 These and other aspects, objects, features and advantages of the present invention will be more clearly understood and appreciated from a review of the following detailed description of the preferred embodiments and appended claims, and by reference to the accompanying drawings.

Advantageous Effect Of The Invention

30 The invention has the following advantages. It provides for low noise, high sensitivity multiple resolution imaging from a single image sensor.

BRIEF DESCRIPTION OF THE DRAWINGS

Fig. 1 is a block diagram for the sensor of a first embodiment of the present invention;

5 Fig. 2 is an architecture diagram for the sensor of a first embodiment of the present invention;

Fig. 3 is a timing and block diagram for color difference readout;

Fig. 4 is a schematic diagram of a four transistor active pixel;

10 Fig. 5a is a block diagram for the sensor of a third embodiment of the present invention;

Fig. 5b is an alternative embodiment of Fig. 5a with column banks at twice the pixel pitch;

Fig. 6a is a first timing and block diagram for operation of the sensor shown in Fig. 2;

15 Fig. 6b is a timing and block diagram for operation of a second embodiment of the present invention;

Fig. 6c is an operational block diagram for adjacent sample averaging operation of the sensor shown in Fig. 5a;

20 Fig. 6d is a second operational block diagram for two row readout operation of the sensor shown in Fig. 5a;

Fig. 7 is a schematic diagram of a pixel architecture of the present invention;

Fig. 8a is a block diagram of a first reduced resolution readout operation of the present invention;

25 Fig. 8b is a block diagram of a second reduced resolution readout operation of the present invention;

Fig. 8c is an operational block diagram of reduced resolution readout operation of the present invention;

30 Fig. 9 is a block diagram of a first reduced resolution readout operation of the third embodiment of the present invention;

Fig. 10 is a block diagram of a second reduced resolution readout operation of the third embodiment of the present invention; and

Fig. 11 is a camera for implementing all of the disclosed embodiments of the present invention.

DETAILED DESCRIPTION OF THE INVENTION

5 The examples and diagrams provided in the description of the present invention represent one preferred embodiment of the present invention. Numerous other specific embodiments are feasible without departing from the scope of the present invention.

Referring to Fig. 1, there is shown a top level block diagram of the
10 image sensor 10 of the present invention. The sensor array comprises a plurality of pixels 20. The pixels 20 can be any known APS or PPS x-y addressable pixel design. Two column circuit banks 80 (also referred to as storage regions), each comprising a plurality of column sample and hold circuits (not shown in Fig. 1) are electrically connected to the output signal lines 90 of the sensor array 10. Two
15 parallel analog signal processing (ASP) chains 110 (also referred to as readout regions) are respectively connected to each column circuit bank 80. An analog to digital converter (ADC) 120 is electrically connected to each processing chain 110 for digitizing the signal. A 2:1 digital multiplexer 130 is connected to both analog to digital converters 120 for selectively selecting the output from the two analog
20 to digital converters 120. A digital signal processing (DSP) block 140 receives the signal from the multiplexer for further processing the signal. An interface is provided to operate and program various modes and specific parameters for the sensor.

Referring to Fig. 2, there is shown a block diagram of a plurality of
25 pixels 20 arranged in rows and columns, mated to a color filter (indicated by the letters R, G, B) for permitting each pixel to selectively receive light of a specific color determined by the bandpass of the color filter. In this figure the color filter pattern is a Bayer pattern, of red (R), green (G) and blue (B) bandpass filters. The R, G and B letters in each pixel denote the color filter associated with that pixel.
30 In addition the letters E and O in each pixel denote the row and column identification as Even and Odd. For example the letters EO denote a pixel is in an even row and an odd column. For ease of detailed viewing, the diagram shows

four rows and six columns, which are only a section of the imaging array and associated circuits. Two column circuit banks 80 include a plurality of column sample and hold circuits 150, which are electrically connected to the columns of pixels. More specifically, each bank comprises three column sample and hold
5 circuits 150 that are each electrically connected to two columns of pixels 20 via a two-to-one pixel output analog multiplexer 160 that enables sample and hold of the signals from either of the two columns of pixels into either of the associated column circuits. As previously shown in Fig. 1, each column bank 80 is connected to an associated ASP chain 110 and ADC 120. In this example, the
10 column sample and hold circuits 150 are constructed at twice the pixel pitch. This provides the advantage of being able to realize a low noise column sample and hold circuit for small pixels. The fixed pattern noise is improved by having more space for signal isolation and layout matching. Temporal noise of the column sample and hold circuit 150 can be reduced by using larger capacitors and
15 switches. The physical floor plan could be implemented with one bank at the top of the array and one bank on the bottom of the array, or both banks could also be stacked on a single side of the array.

As stated previously, one disadvantage with the prior art two channel architecture is offset and gain matching between the two channels. This
20 will lead to green non-uniformity (GNU) artifacts.

Still referring to the architecture in Fig. 2, the dashed lines with arrows within each column indicate which direction or bank of column circuits that the specific pixel is sampled and held in for a first preferred embodiment of the present invention. In this first configuration, all pixels of a particular color in
25 a row are sent to a common column circuit bank. For example, all red pixels in even rows are sent to column circuit bank 2, and all green pixels in even rows are sent to column circuit bank 1. In odd rows, all blue pixels are sent to column circuit bank 2 and all green pixels are sent to column circuit bank 1. In this manner, the green color plane would go through a single ASP chain 110 and ADC
30 120, while red and blue would go through the other ASP chain 110 and ADC 120. As a result, no offset or gain mismatch would occur between green pixels in the green-red row (Gr), and green pixels in the green-blue row (Gb). This is

accomplished by timing of the pixel output multiplexer 130. This specific timing for this example is shown in Fig. 6a. The signals Bank1_e and Bank1_o determine if the even and odd pixels respectively in a given row are sent to column circuit bank 1. Bank2_e and Bank2_o serve the same purpose for column circuit bank 2. For odd rows, Bank1_e is high, Bank1_o is low, Bank2_e is low and Bank2_o is high. For even rows, Bank1_e is low, Bank1_o is high, Bank2_e is high and Bank2_o is low. This color plane separation approach enabled by the present invention can mitigate the GNU issue. In general, the timing of the pixel output multiplexers can be used to send any pixel to either or both of the associated column sample and hold circuits.

Because of the color plane separation afforded by the selectable dual channel architecture, it is now possible to average like color signals in a pipelined manner because each column circuit bank and ASP chain contains samples of the same color for any given row. Also, by operating in this manner, a pixel rate White Balance (WB) Programmable Gain Amplifier (PGA) is not needed since for any given row, each ASP chain 110 contains signals from a single color plane. In this case the WB PGA must change at a line rate and alternate between Gr and Gb for ASP chain 1, and R and B for ASP chain 2. ASP chain 1 and chain 2 are identical, and operate at one half the final pixel output data rate.

In another configuration of this same architecture, a color difference readout can be provided. The color difference readout operation will be described using the four transistor active pixel shown in Fig. 4, although the other pixel architectures can be used without departing from the scope of the invention. Referring to the sensor block diagram and timing diagram in Fig. 3, color difference readout is accomplished in the following manner. Referring to both Figs. 3 and 4, after integration is completed, readout of the row 1 commences after reset of the floating diffusions 190 of the pixels in that row, (a green-red row in this example). The reset level of the floating diffusion 190 in the green pixel is then stored as the reference level in one column circuit bank 80. This is referred to as Resetg. Next the signal in the photodiode 170 is transferred to the floating diffusion 190 for all pixels in the row. The signal level on the floating diffusion

190 in the red pixels is now stored as the reference level in the second column circuit bank 80. This voltage level stored is $R + \text{Resetr}$. Next the signal level of the floating diffusion 190 in the green pixel is stored as the signal level in both column circuit banks. This is $G + \text{Resetg}$. Readout of the stored signal now
5 commences. One column bank 80 produces a true correlated double sample readout of the green signal level as shown in equation 1.

$$(\text{Green} + \text{Resetg} - \text{Resetr}) = G \quad (1)$$

10 The other column circuit bank provides a color difference signal readout as shown in equation 2.

$$(\text{Green} + \text{resetg}) - (\text{Red} + \text{resetr}) = (G - R) + (\text{Resetg} - \text{Resetr}) \quad (2)$$

15 This process repeats for all rows in the sensor.

Another embodiment of the selectable dual channel sensor architecture of the present invention is shown in Fig. 6b. The analog multiplexers (160 in the previous Figures) are eliminated and separate control of sample and hold signals for each bank are provided. These signals are labeled SHS_e and
20 SHS_o for sample and hold signal even and odd respectively, and SHR_e and SHR_o for sample and hold reference even and odd respectively. These are provided separately for column circuit banks 1 and 2 (80) and denoted in Fig 6b accordingly. The analogous timing for Fig. 6a with this architecture is shown in Fig. 6b. In general the timing of the bank sample and hold signals can be used to
25 send any pixel to either or both of the associated column sample and hold circuits 150.

An alternate sensor architecture is shown in Figs. 5a and 5b. In the case of Fig 5a, there are two banks of column sample and hold circuits 80, but the column sample and hold circuits 150 are constructed at the pixel pitch. The pixel
30 output multiplexer 160 is now a 2:2 configuration where the odd and even pixel in a given row can be sent to one of two, or both column sample and hold circuits 150 associated with that multiplexer 160. Details of multiplexer 160 are not

shown and can be any configuration known in the art. Fig 5b is electrically equivalent to Fig 5a, except that the column banks 80 are split into two sub-banks 150 that are constructed at twice the pixel pitch. This stacked or staggered approach shown in Fig. 5b retains the advantages of a wider column circuit as described for the architecture of Fig. 2.

The same color plane separation can be accomplished with the two channel sensor architectures of Figs. 5a and 5b in a similar manner as described for the sensor architecture of Figs 2 and 3. The sensor architectures of Fig. 5a and 5b provide an additional capability over that already described. Because the column sample and hold circuits 150 are built at the pixel pitch, the two channel architecture can effectively store and readout two samples of each pixel in a single row of image data simultaneously. By timing the pixel output multiplexer 160, two samples of the pixel value in each row of sensor data can be stored with the color planes separated for efficient adjacent sample averaging. This is shown in Fig 6c. Again the operation is described in the context of the pixel shown in Fig. 4 in a rolling shutter mode. Other pixel architectures and modes of operations can be used without departing from the scope of the invention. After integration ends, sample and hold of row 0, an even row, commences. Each Gr pixel signal level is stored in two adjacent column locations of column circuit bank 1 (80) by using the pixel output multiplexer 160 to connect the Gr pixel output to both of the associated column sample and hold circuits 150 in bank 1 (80). Each of the G pixels stored in the respective column sample and hold circuit is labeled as G0X, where 0 denotes row zero and X denotes the column number in that row. As shown in Fig. 6c each G pixel in the row gets stored in two adjacent column locations in column circuit bank 1 (80). Similarly each of the R signal values in row 0 is sampled and held in two adjacent column sample and hold circuits 150 in bank 2 (80). Now the two banks (80) can be read out in parallel and the two adjacent stored signals from a single pixel can be averaged to create a lower noise value. The average is most easily accomplished in the digital domain after analog to digital conversion. The process is repeated for the next row, an odd row, where two samples of Gb are stored in bank 1 (80), and two adjacent samples for each B

are stored in bank 2 (80). In general, this approach can be employed with n-sample and holds connected to a single pixel to provide n-sample averaging.

The same color plane separation afforded by the two channel sensor architecture of Figs. 2 and 6b can also be accomplished with the two channel sensor architecture of Figs. 5a and 5b by storage and readout of two rows in parallel. Referring to Fig. 6d, after integration ends sample and hold of row 0, an even row, commences. Each Gr pixel signal level is stored in even column locations of column circuit bank 1 (80) by using the pixel output multiplexer 160 to connect the Gr pixel output to the even column locations of the associated column sample and hold circuits 150 in bank 1 (80). Similarly each of the R pixel signal values is sampled and held in the odd column sample and hold circuits 150 in bank 2 (80). Next row 1, an odd row is sampled and held. Each Gb pixel signal level is stored in odd column locations of column circuit bank 1 (80) by using the pixel output multiplexer 160 to connect the Gb pixel output to odd column locations of the associated column sample and hold circuits 150 in bank 1 (80). Similarly each of the B pixel signal values is sampled and held in the even column sample and hold circuits 150 in bank 2 (80). Now the two banks (80) can be read out in parallel. This is shown in Fig 6d by placement of specific R, G and B pixels in the column circuits with a value of C_{xy} , where C denotes the color, x denotes the row and y denotes the column. For example B10 is the blue pixel in row 1 and column 0. This process is repeated for each group of two rows in the array. By storage and readout in this manner, a 2x2 region of the array is always available in the digital domain and this can be utilized for on-chip pipelined color processing.

It should be noted that any pixel architecture can be used in conjunction with this selectable two channel storage and readout architectures described in the present invention without departing from the scope of the invention. Further the dual channel concept can be extended to multiple channels with the ability to store and readout any pixel in any bank.

Further advantages of the selectable multi-channel sensor architecture can be realized by use of a specific pixel architecture. A shared amplifier pixel can be employed with the selectable two-channel sensor

architecture, to enable charge domain binning and adjacent sample averaging to provide higher sensitivity and lower noise for cases where lower resolution still images or low light, lower resolution video is desired. One example of an envisioned embodiment of the shared pixel architecture is shown in Fig. 7.

5 Referring to Fig. 7, there is shown a schematic drawing of a shared amplifier pixel of the present invention. This pixel architecture enables charge domain binning of the same color pixels, as well as charge domain binning of all pixels that share the same amplifier. Although this pixel is used as a preferred embodiment of the present invention, other pixel architectures can be employed
10 for both charge domain binning, and for use in the selectable dual channel storage and readout architecture. Four pixels 20 are shown in the drawing. These four pixels 20 are arranged in a column, such that each pixel 20 is associated with a given row. This set of four pixels 20 comprises a sensor array unit cell. Each pixel comprises a photodetector 170, and a transfer gate 180. The floating
15 diffusion 190, reset transistor 200 with a reset gate 210, source follower input transistor 220, row select transistor 230, and output signal line 240 are shared between the four pixels. A plurality of unit cells comprises the sensor array. Other specific embodiments are possible and readily apparent to someone skilled in the art.

20 There are four TG signals and one RG signal associated with a single row select line. This will be referred to as a four-shared pixel. As a result of the four-shared pixel, four photodiodes share the same floating diffusion node. Since the color pattern within a column is alternating colors, (e.g. G,R or B,G), photoelectrons collected in the same color photodiode can be summed or binned
25 on the common floating diffusion (FD) by transferring of charge from the appropriate sets of photodiodes onto the FD. This will increase the effective responsivity or sensitivity of the sensor since the number of electrons collected for any given light level or integration time will be doubled. In addition, for very low light conditions where color information is not absolutely necessary, all four
30 photodiode signals can be binned onto the common FD, further increasing sensitivity.

In the first example a 16x resolution reduction of the full resolution image is accomplished. For example, a two megapixel sensor of 1632 x 1224 pixels would be reduced down to an image of 408 x 306. The resolution reduction is done by combining signals from a four pixel by four pixel area into a single new picture element referred to as a paxel 300. This paxel 300 is shown in Fig. 8a. Referring to Figs. 2, 7, 8a and 8c, the rolling shutter start is applied to even and odd row pairs in the four rows of the paxel 300, so that the even and odd rows in the paxel 300 will have the same integration time. At the end of the desired integration readout begins for the even rows by reset of the FD 190 by pulsing RG 210 and storage of the reset level in the column sample and hold circuit 80, then pulsing TG 180 to transfer charge from the PD 170 to the FD 190 followed by storage of the signal + reset level in the column sample and hold circuit. This is done for row 0 and 2 simultaneously, (i.e. row select is on for the four-shared group, RG 210 is pulsed, reset level is sampled and held, TG0 (310) and TG2 (320) are pulsed simultaneously, this signal level is then sampled and held). At this point we have the two Green pixels binned on the floating diffusion of the even columns, and the two Red pixels binned on the floating diffusion 190 of the odd columns. This is denoted in Fig 8c as the sum of two pixel values located in the respective column sample and hold circuit 150. The Green signals will be pipelined through one ASP channel, and the Red signals will be pipelined through the other ASP channel, as described in the dual channel architecture operation.

Now a key advantage of the dual channel architecture column can be employed. Because the signals stored in the respective ASP channels are the same color, adjacent signal samples can be directly and simply averaged in a pipelined manner to create a single value from the two adjacent color values in the 4x4 paxel. For example, after the ADC's 120 the two adjacent samples of each color, (2-Gr's and 2-R's), are averaged digitally and output as a single 10 bit R value and Gr value. This is shown in Fig. 8c. In this case the R and Gr value are actually derived from four individual pixels, two pixels binned in the charge domain and two binned values averaged in the digital domain. Thus sensitivity is increased and noise is reduced.

Next the odd rows in the paxel 300 are read out in a similar manner, (same as even rows except TG1 315 and TG3 325 are pulsed simultaneously). The Blue pixels are binned in the even columns and the Gb pixels are binned in the odd columns. The Gb values are sampled and held and then pipelined through the same channel as Gr, while the Blue values are sampled and held and then pipelined through the same channel as the Red pixels. The two adjacent values of B and Gb can now be digitally averaged, and single 10 bit values of B and Gb can be output from the sensor. The Gr and Gb values can be averaged off chip if desired to further reduce noise.

This approach has several advantages over the prior art sub-sampling method of APS devices. First, sensitivity is increased. Second, noise is reduced. This leads to a higher dynamic range. Additionally, aliasing artifacts caused by sub-sampling are not produced.

This same charge domain binning and voltage or digital domain adjacent sample averaging can be utilized with the sensor architecture of Figs. 5a and 5b. The sensor architectures of Fig. 5a and 5b provide an additional capability over that already described. Because the column sample and hold circuits 150 provided at the pixel pitch, the two channel architecture can effectively store two rows of image data simultaneously. By timing the pixel output multiplexer two rows of sensor data can be stored with the color planes separated for efficient adjacent sample averaging. Referring to Figs. 5a, 7, and 6c, it follows that R', B', Gr' and Gb' pixel values can be stored in the column circuit banks 80 as shown in Fig. 9, where R', B', Gr' and Gb' are the charge domain binned values for the paxel. These are denoted in Fig. 9 as the sum of two pixel values shown in each column circuit 150 location. Gr' and Gb' are stored in Bank 1 (80), and R' and B' are stored in bank 2 (80) as previously described. Now adjacent values of each color can be averaged in a pipelined manner as the sensor is read out.

Additionally, since all color values are now available at the same time, no interpolation is required to get an RGB value per 4x4 paxel. The RGB per paxel 300 can also be easily converted selectively to YUV or YCC on chip in the digital domain. White balance and color correction could also be done simply

for each paxel digitally. This is an advantage for direct output video for camera preview modes and other video modes.

Referring to Figs. 10 and 8b , a 4x reduction in resolution can be accomplished. B10 and R01 become the B and R values for paxel 400

5 respectively, and the average of G00 and G11 become the G value for paxel 400. The readout is done in the same manner as full resolution mode, (for row 0, Gr is readout out through 1 ASP chain 110, R is readout through the other; for row 1, Gb is readout through 1 ASP chain and B is readout through the other). G channel averaging is done in the DSP block 140.

10 Fig. 11 is a camera 500 for implementing all of the disclosed embodiments of the present invention.

The foregoing discussion describes the embodiments most preferred by the inventor. Numerous variations will be readily apparent to those skilled in the relevant art. Therefore, the scope of the invention should be
15 measured not by the disclosed embodiments but by the appended claims.

The invention has been described with reference to a preferred embodiment. However, it will be appreciated that variations and modifications can be effected by a person of ordinary skill in the art without departing from the scope of the invention.

PARTS LIST

10	image sensor (or sensor array)
20	pixels
80	column circuit banks (or storage regions)
90	output signal lines
110	analog signal processing (ASP) chains (or readout regions)
120	analog to digital converter (ADC)
130	2:1 digital multiplexer/pixel output multiplexer
140	digital signal processing (DSP) block
150	column sample and hold circuits
160	two-to-one pixel output analog multiplexer
170	photodiode/photodetector
180	transfer gate
190	floating diffusion
200	reset transistor
210	reset gate
220	source following input transistor
230	row select transistor
240	output signal line
300	paxel
310	TG0
315	TG1
320	TG2
325	TG3
400	paxel